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**AMENDMENT TO THE CLAIMS**

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**Claims 1-6 (canceled).**

**Claims 7-10 (withdrawn).**

**Claim 11-13 (canceled).**

**Claim 14 (previously added):** The sputtering target according to claim ~~14~~ 27, wherein said alloy contains multiple phases comprising CoB, CoCrB, CoCr, CoPt, CoCrPt, and Pt uniformly distributed in the alloy.

**Claim 15 (canceled).**

**Claim 16 (amended):** The sputtering target according to claim ~~17~~ 27, wherein said alloy further includes tantalum and said alloy comprises Co-20Cr-10Pt-2Ta-5B.

**Claim 17 (canceled).**

**Claim 18 (amended):** The sputtering target according to claim ~~17~~ 28, wherein said alloy comprises Co-19Cr-11Pt-8B.

**Claim 19 (amended):** The sputtering target according to claim ~~17~~ 28, wherein said alloy comprises Co-15Cr-11Pt-10B.

**Claim 20 (amended):** The sputtering target according to claim ~~7~~ 28, wherein said alloy comprises Co-20Cr-10Pt-6B.

**Claim 21 (amended):** The sputtering target according to claim 7 28, wherein said alloy comprises Co-10Cr-10Pt-20B.

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**Claim 22 (amended):** The sputtering target according to claim 7 28, wherein said alloy comprises Co-12Cr-12Pt-18B.

**Claim 23 (amended):** The sputtering target according to claim 7 28, wherein said alloy comprises Co-12Cr-8Pt-22B.

**Claim 24 (amended):** The sputtering target according to claim ~~14~~ 27, wherein the atomic % of B ranges from 2 atomic % to 30 atomic %.

**Claim 25 and 26 (canceled).**

**Claim 27 (new):** A precious metal magnetic sputtering target comprising a mechanically alloyed, chemically homogeneous alloy composition having microstructural homogeneity, said alloy composition comprising Pt, Co, Cr, and at least 2 atomic % B.

**Claim 28 (new):** The sputtering target according to claim 27, wherein the atomic % of B is at least 6 atomic %.

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